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Electrochemical synthesis and the gas sensing properties of the Cu₂O nanofilms/porous silicon hybrid structure

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Abstract

A novel composite of Cu₂O nanofilms/porous silicon hybrid structure has been successfully synthesized using porous silicon as growth substrate by electrochemical synthesis. Orderly porous silicon (PS) substrate with the aperture about 1.5 μm and hole depth about 10 μm was prepared by electrochemical etching of a p-type monocrystalline silicon wafer in a double-tank cell. The Cu₂O nanofilms have been grown onto PS substrates by electrochemical deposition with different electrodeposition time. The obtained Cu₂O nanofilms/PS products were investigated by X-ray diffraction (XRD), scanning electron microscopy (SEM) and transmission electron microscope (TEM). The gas sensing properties of Cu₂O nanofilms/PS composites to NO₂ were studied by the gas sensing test system. The result indicates that the electrodeposition time has a significant impact on the microstructure and gas sensing properties of Cu₂O nanofilms/PS composites. Due to the high specific surface area and special microstructure, the Cu₂O nanofilms/PS gas sensor with the electrodeposition time of 30 min showed good gas sensing properties to NO₂ with a high gas response, fast response-recovery characteristic, excellent repeatability and good selectivity at a working temperature of 175 °C. At the working temperature, the gas sensor has a gas response of about 4.5 to 1 ppm NO₂. The related gas sensing mechanism will be discussed.

Keywords

Cuprous oxide; Nanofilms; Porous silicon; Electrochemical deposition; Gas sensor

1. Introduction

Nitrogen dioxide (NO₂) is one of the most toxic gases in the atmosphere which results from combustion and automotive emission[1]. According to the Italian regulation, the air-quality standard for NO₂ of attention level in the ambient air is 100 ppb for long-term exposure[2]. Therefore, the development of detector for NO₂ has attracted intensive attention. The NO₂ gas sensors with some characteristics such as a high gas response, short response-recovery time, low power consumption and low cost are demanded, but not yet marketed.

Porous silicon (PS) is an important porous medium which is sensitive to many gases such as

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